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Applicant(s)

Min-hyung LEE, et al.

Filing Date

11/16/2005

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U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
		4,273,622	6/16/1981	Becker	203	28	11/26/1979
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FOREIGN PATENT DOCUMENTS

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							YES	NO
		WO 99/42426 A1	8/26/1999	PCT				
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		Nishiguchi, T.; Kamio, C. J. Chem. Soc. Perkin Trans., 1, 1989, ppp. 707-710
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All the references cited in the Search Report are listed above

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